

19 March 2003

Updated Search

09/866,665

L Number	Hits	Search Text	DB	Time stamp
1	4082	(silicon with cvd with plasma) and oxygen	USPAT; US-PGPUB; EPO; JPO; DERWENT	2003/03/19 13:54
2	72	((silicon with cvd with plasma) and oxygen) and (silicon adj fluoride)	USPAT; US-PGPUB; EPO; JPO; DERWENT	2003/03/19 13:57
3	159	((silicon with cvd with plasma) and oxygen) and ((silicon adj fluoride) or (silicon adj tetrafluoride) or tetrafluorosilane or perfluorosilane)	USPAT; US-PGPUB; EPO; JPO; DERWENT	2003/03/19 13:58
4	446	((silicon with cvd with plasma) and oxygen) and ((silicon adj fluoride) or (silicon adj tetrafluoride) or tetrafluorosilane or perfluorosilane or "siF.sub.4")	USPAT; US-PGPUB; EPO; JPO; DERWENT	2003/03/19 13:58
5	4575	((silicon adj fluoride) or (silicon adj tetrafluoride) or tetrafluorosilane or perfluorosilane or "siF.sub.4") and (((plasma adj chemical) or PECVD or (plasma adj enhanced) or (plasma adj cvd)) with silicon)	USPAT; US-PGPUB; EPO; JPO; DERWENT	2003/03/19 14:01
6	738	((silicon adj fluoride) or (silicon adj tetrafluoride) or tetrafluorosilane or perfluorosilane or "siF.sub.4") and (((plasma adj chemical) or PECVD or (plasma adj enhanced) or (plasma adj cvd)) with silicon)	USPAT; US-PGPUB; EPO; JPO; DERWENT	2003/03/19 14:01
7	560	((silicon adj fluoride) or (silicon adj tetrafluoride) or tetrafluorosilane or perfluorosilane or "siF.sub.4") and (((plasma adj chemical) or PECVD or (plasma adj enhanced) or (plasma adj cvd)) with silicon)) and ((oxygen or "o.sub.2"))	USPAT; US-PGPUB; EPO; JPO; DERWENT	2003/03/19 14:02
8	84	((silicon adj fluoride) or (silicon adj tetrafluoride) or tetrafluorosilane or perfluorosilane or "siF.sub.4") and (((plasma adj chemical) or PECVD or (plasma adj enhanced) or (plasma adj cvd)) with silicon)) and ((oxygen or "o.sub.2") with concentration)	USPAT; US-PGPUB; EPO; JPO; DERWENT	2003/03/19 14:02